

Search Notes	Application No.	Applicant(s)
	10/620,125	HORIUCHI ET AL.
	Examiner (Nancy) Thanh-Nhan P Nguyen	Art Unit 2871

SEARCH NOTES (INCLUDING SEARCH STRATEGY)		
	DATE	EXMR
349/187.ccls. and (plastic adj substrate\$); 349/187,189.ccls. and ((vacuum adj chamber) (vacuum adj condition\$))	1/11/2005	TN
349/187,189.ccls. and (method process) and vacuum and atmosphere\$;	1/11/2005	TN
349/187,189.ccls. and ((cur\$) with (seal\$ adj (material agent)));	1/12/2005	TN
349/\$.ccls. and ((substrate\$) with (vacuum with (atmospher\$)))	1/12/2005	TN34
349/158.ccls. and ((vacuum adj chamber) (vacuum adj condition\$) (low adj pressure) (reduced adj pressure))	1/12/2005	TN
349/123-126.ccls. and (alignment with (embossed roughened)) and vacuum	1/19/2005	TN